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Dated: February 10, 2005

Signature: \_\_\_\_\_

(Michael R. Hull)

Docket No.: 30205/39512  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Sung Koo Lee et al.

Allowed: February 3, 2005

Application No.: 10/719,355

Confirmation No.: 3322

Filed: November 21, 2003

Art Unit: 1752

For: PHOTORESIST POLYMER AND  
PHOTORESIST COMPOSITION  
INCLUDING THE SAME

Examiner: Sin J. Lee

**COMMENTS ON STATEMENT OF REASONS  
FOR ALLOWANCE UNDER 37 CFR §1.104(E)**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In addition to the reasons for allowance set forth in the allowance papers that were mailed in connection with the present application, it is respectfully submitted that the claims are allowable for the additional reasons that the invention defined by the language of the claims is neither anticipated by, nor would have been obvious when taken as a whole in view of, the art of record.

Dated: February 10, 2005

Respectfully submitted,

By \_\_\_\_\_  
Michael R. Hull

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